

Copper

SLOTOCOUP PRT 120

The Copper SLOTOCOUP PRT 120 has been developed in order to optimize the benefits of periodic reverse pulse plating in continuous vertical plating lines.

With Reverse Pulse Plating, Copper SLOTOCOUP PRT 120 deposits fine-grained copper layers with excellent metal distribution at considerably reduced plating times. The electrolyte is operated with only one additive.

SLOTOCOUP PRT 120 can also be operated as a traditional DC plating (direct current) electrolyte, then it deposits bright, fine-grained, ductile layers.

The information in this data sheet is based on laboratory as well as practical experience. Figures quoted for operating limits and replenishment quantities are for guidance. Actual values necessary will depend on the components being plated (material and geometry), their application and plating plant conditions.

Important:

Please read this instruction carefully prior to the use of the process and carefully follow all the parameters that have a direct influence on the operation. We reserve the right to make technical changes. In the interest of safety, please pay attention to the hazard warnings on the labels of the containers. The minimum shelf life of the products is included on the labels and is also available in the appropriate Quality Assurance (QA03).

The current IMDS number of the layer deposited from the process is available on the internet at www.schloetter.com/downloads.

For the storage of chemical products the TRGS 510 must be followed.

If the additives used in this process contain a SVHC-substance, then this will be specified in the corresponding Material Safety Data Sheet, section 15.

